High temperature ferromagnetism in Ni-doped In$_2$O$_3$ and indium-tin oxide

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Observation of high temperature ferromagnetism in Ni-doped In$_2$O$_3$ and indium-tin-oxide (ITO) samples prepared by a solid state synthesis route is reported. Both Ni-doped compounds showed a clear ferromagnetism above 300 K with the magnetic moments of 0.03–0.06 μ$_B$/Ni and 0.1 μ$_B$/Ni at 300 and 10 K, respectively. Ni-doped In$_2$O$_3$ samples showed a typical semiconducting behavior with a room temperature resistivity of ρ ~ 2 Ω cm, while Ni-doped ITO samples were metallic with ρ ~ 2 x 10$^{-2}$ Ω cm. Analysis of different conduction mechanisms suggested that variable range hopping model explains our ρ-T data for the Ni-doped In$_2$O$_3$ sample the best. © 2006 American Institute of Physics. [DOI: 10.1063/1.2220529]

Since the discovery of the giant magnetoresistance (GMR) effect in metallic multilayer structures, much effort has been put into developing and finding new materials that utilize the spin of electrons. Usually diluted magnetic semiconductors (DMSs) are formed when magnetic transition metal ions, such as 3d elements, are doped into the host lattice of a semiconductor. Theoretical predictions by Dietl et al. have boosted the search for ferromagnetism in the transition metal doped ZnO. The obtained results are very controversial, where some groups claimed that this system is ferromagnetic, while others have found no ferromagnetism in TM doped ZnO. Recently, high temperature ferromagnetism was observed in Co-doped SnO$_2$ with large magnetic moment ~7.5 μ$_B$/Co. However, this giant magnetic moment was found only in as prepared samples. Due to the small solubility of magnetic ions in the host semiconductor, ferromagnetism probably is induced by the clusters of dopants formed during the sample preparation procedure.

If one considers integrating electronic, magnetic, and photonic properties in the new generation devices, the materials suitable for such devices should have high tunability of charge carriers, high carrier mobility, optical transparency, high abundance of the consisting elements, and low impact on the environment. In$_2$O$_3$ is one of the most promising candidates for such tasks. It is a well known semiconductor oxide already used practically worldwide. When In$_2$O$_3$ is doped with Sn, a so called indium-tin-oxide (ITO) is formed. High conductivity of ITO is attributed to the high carrier concentration which is caused by incorporation of Sn ions into In$_2$O$_3$ host lattice and oxygen nonstoichiometry. ITO has a cubic bixbyite structure with the lattice parameter a = 10.118 Å. Electrical conductivity (σ) for best quality ITO samples was found to be ~10$^4$ S/cm.

Recently, Yoo et al. and He et al. have reported both bulk and thin film samples of a diluted magnetic semiconductor—Fe and Cu codoped In$_2$O$_3$ oxide. The solubility of Fe ions in the host compound was found to be around 20%, which is very high. In addition to that Ni-doped In$_2$O$_3$ thin films were also found to be ferromagnetic at room temperature, although the doping level of Ni (~6 wt %) was not as high as for samples reported in Ref. 13. Hong et al. showed that Ni is distributed uniformly throughout the film, which suggests that clustering of Ni particles in the samples is very unlikely. Hence, this fact gives a firm ground for assumption that observed ferromagnetism in their samples is rather intrinsic property of material. It is important to note that laser ablation technique used in Ref. 15 is a synthesis technique that is nonequilibrium. Therefore, samples prepared under equilibrium conditions, exhibiting same properties would confirm observed magnetic phenomena. In this letter we report on the observation of room temperature ferromagnetism in Ni-doped In$_2$O$_3$ and ITO.

Polycrystalline samples of In$_{2-x}$Ni$_x$O$_3$ and In$_{2-x}$Ni$_x$Sn$_{0.02}$O$_3$ (1% Sn doping) were prepared by a conventional solid state synthesis technique. In$_2$O$_3$ and SnO$_2$ were factory prepared chemicals (high purity: 99.99%, Aldrich). Black NiO was prepared after decomposition of Ni(OH)$_2$ (high purity: 99.99%, Aldrich) in tube furnace at 300 °C for 2 h in air. Starting materials were weighed and mixed in a mortar in corresponding ratios to obtain nominal chemical compositions for the final products. Mixed powders were calcined in an argon atmosphere at 850 °C for 12 h. After that, the reacted powders were reground, pressed into the pellets, and fired at 950 °C for 12 h in an argon atmosphere. The phases and crystal structure of samples were analyzed by means of x-ray diffraction technique (XRD) using Cu Kα irradiation (Mac Science; M03 XHF22). Figure 2 shows the XRD patterns of the pulverized pellets of In$_{1.95}$Ni$_{0.05}$O$_3$ and In$_{1.95}$Ni$_{0.05}$Sn$_{0.02}$O$_3$. The observed diffraction patterns correspond to that of cubic In$_2$O$_3$ phase. Lattice parameter a calculated from Rietveld refinements of the x-ray diffraagrams showed some slight deviation from the literature data of a = 10.118 Å, i.e., a(In$_{1.95}$Ni$_{0.05}$O$_3$) = 10.121 Å and a(In$_{1.95}$Ni$_{0.05}$Sn$_{0.02}$O$_3$) = 10.119 Å.

Transport properties were investigated using four point technique utilizing Physical Property Measuring System (PPMS, Quantum Design). Measurements were performed in a temperature range from 350 down to 5 K. Figure 2 represents the dependence of the electrical resistivity (ρ) on temperature (T) for both samples. Ni-doped In$_2$O$_3$ shows a characteristic semiconducting behavior, while Ni-doped ITO clearly exhibits a metallic behavior with much lower ρ. The absolute value of ρ at 300 K of In$_{1.95}$Ni$_{0.05}$O$_3$ was found to be ρ = 2 Ω cm, which is in a good agreement with published data for Ni-doped In$_2$O$_3$ thin films. At 300 K In$_{1.93}$Ni$_{0.05}$Sn$_{0.02}$O$_3$ sample has ρ = 2.02 x 10$^{-2}$ Ω cm.
rather high resistivity of our Ni-doped ITO sample could be explained by probable porosity of the sample due to the preparation conditions (Ar atmosphere). Furthermore, as we can see from the inset in Fig. 2, there is a minimum point \( T = 123 \text{ K} \) in the \( \rho-T \) curve for Ni-doped ITO sample. One should consider two different mechanisms in two temperature ranges. When \( T > 123 \text{ K} \), the temperature dependent electrical transport mechanism of the system should have negative temperature coefficient of resistivity (TCR). Then, if \( T < 123 \text{ K} \), the TCR changes its value to +1. It is hard to explain what happens and why the sign of TCR changes. Edert et al.\textsuperscript{16} have argued that at temperatures above 123 K metallic behavior in electrical resistivity curves can be caused due to the sintering of conducting clusters, which lead to formation of conducting paths through the sample. Below \( T = 123 \text{ K} \) the resistivity is dominated by ionized impurity scattering and thus TCR becomes positive.

Various electrical transport models were applied in order to understand which transport mechanism explains the \( \rho-T \) data of \( \text{In}_{1.95}\text{Ni}_{0.05}\text{O}_3 \) sample the best. Firstly hopping conduction models were investigated. Generally hopping conduction can be represented by Eq. (1),

\[
\rho = B_2 \exp \left( \frac{B_1}{T} \right)^{1/q},
\]

where \( B_1, B_2, \) and \( q \) are constants, and \( T \) is temperature. A conduction mechanism dominated by hopping between localized states distributed randomly in the material [variable range hopping (VRH)] has a temperature dependence described by Eq. (1) with \( q=4 \). When \( q=1 \) localized states are distributed in periodic array [nearest neighbor hopping (NNH)]. Secondly, a granular-metal (GM) system model was considered. In such system metallic grains are separated by thin insulating layers and \( q=2 \). Lastly, we have tried to fit our data with regard to degenerate semiconductor (DS) model, which is expressed by Eq. (2),

\[
\rho(t) \propto t^{-3/2}.
\]
sponds to that when $q=4$, i.e., VRH model [Fig. 3(a)]. Other curves showed large deviation from the linear fits in the same temperature range, e.g., NNH model [Fig. 3(b)]. Thus, VRH conduction mechanism explains transport properties of our Ni-doped In$_2$O$_3$ sample the best.

The magnetization ($M$) versus temperature ($T$) data for Ni-doped In$_2$O$_3$ and ITO samples are shown in Fig. 4. The zero field cooled (ZFC) measurements were done during warming in a field of 2000 Oe (Quantum Design, MPMS XL). Both samples were found to be ferromagnetic in the whole temperature range. The insets in Fig. 4 show magnetization ($M$) versus applied magnetic field ($H$) at 300 and 10 K. The maximal applied magnetic field varied from 2 to 5 T. Both samples show clear saturation magnetization ($M_s$) at 300 K indicating high temperature ferromagnetism in the system. Observed $M_s$ at 300 K was $M_s=0.06 \mu_B/Ni$ and $M_s=0.03 \mu_B/Ni$ for In$_{1.95}$Ni$_{0.05}$O$_3$ and In$_{1.93}$Ni$_{0.05}$Sn$_{0.02}$O$_3$, respectively. The obtained $M_s$ value for Ni-doped In$_2$O$_3$ is smaller than $M_s=0.7 \mu_B/Ni$ at 300 K reported for Ni-doped In$_2$O$_3$ thin films made by pulsed laser deposition (PLD).\(^{15}\)

On the other hand, our $M_s$ values at 300 K for both compounds are well comparable to those reported for Mn-doped ITO thin films\(^{17}\) and Co-doped In$_2$O$_3$ thin films,\(^{18}\) $M_s=0.08 \mu_B/Mn$ and $M_s=0.05 \mu_B/Co$, respectively. Investigation of $M$-$H$ loops of the 10 K showed that for Ni-doped In$_2$O$_3$ $M$-$H$ loop is still saturated and $M_s=0.1 \mu_B/Ni$, while magnetic response of Ni-doped ITO sample does not have this trend anymore.

Different magnetic mechanisms might be responsible for observed magnetic phenomena in our samples.\(^{19}\) Since our samples are highly conductive, the most “appropriate” model that would somehow support and explain the magnetism in our samples is carrier induced magnetism. It is known that carriers are donated by oxygen vacancies that act as shallow donors. Our samples were prepared under argon atmosphere, suggesting and thus supporting our speculation that the system must be rich in oxygen vacancies and thus itinerant carriers. Itinerant carriers coupled to local moments lead to the well-known Zener–Ruderman-Kittel-Kasuya-Yoshida (RKKY) mechanism of indirect magnetic interaction between the magnetic impurities with consequent induction of ferromagnetic states. On the other hand, $M$-$H$ loops at 300 K (inset Fig. 4) showed that more conductive Ni-doped ITO sample has lower saturation magnetization, which contradicts the above mentioned model. It might be possible that lower portion of Ni ions contributes to the effective magnetic moment of the system. Other models, such as bound magnetic polarons (BMPs) and double exchange interaction, were also considered. In the former case, high conductivity of our samples contradicts requirements for BMP model to work. In the latter case, the probability of Ni being in multivalent state is very small, thus eliminating double exchange interaction mechanism from the list of choices as well.

In summary, polycrystalline Ni-doped In$_2$O$_3$ and ITO samples were prepared. Both compounds were found to be ferromagnetic in the whole temperature range with saturation magnetizations ($M_s$) at 300 K, $M_s=0.06 \mu_B/Ni$ and $M_s=0.03 \mu_B/Ni$ for In$_{1.95}$Ni$_{0.05}$O$_3$ and In$_{1.93}$Ni$_{0.05}$Sn$_{0.02}$O$_3$, respectively. In$_{1.95}$Ni$_{0.05}$O$_3$ transport properties measured showed a typical semiconducting behavior with $\rho(300 K)=2 \Omega$ cm, while Ni-doped ITO was found to be metallic with $\rho(300 K)=2.06 \times 10^{-2} \Omega$ cm. Analysis of the different conduction models suggested that electrical transport in our Ni-doped In$_2$O$_3$ sample is best explained by variable range hopping (VRH) conduction mechanism.

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